

NS6130-10-1066

COPPER

Sulphide Sputtering Target

Quick Facts

Product	: Copper Sulfide Sputtering Target
Stock No	: NS6130-10-1066
CAS	: 1317-40-4
Purity	: 99.9%

Technical Specification

Diameter	Thickness	Molecular Formula
50.8 mm \pm 1mm	3 mm \pm 0.5mm	CuS

Copper Sulfide Sputtering Target is mainly used in the electronics and information industry, glass coating field, wear-resistant materials, high-temperature corrosion resistance, high-grade decorative goods, and other industries.

Applications

- Solar cell
- Semiconductor
- Optical

* This image is for graphic purposes only and does not represent the actual product.

